(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property Organization
International Bureau

(43) International Publication Date
04 September 2025 (04.09.2025)

WIPO | PCT

(10) International Publication Number
WO 2025/184147 A1

(51) International Patent Classification:
*C25D 17/02* (2006.01) *C25D 21/12* (2006.01)
*C25D 17/10* (2006.01) *C25D 21/10* (2006.01)
*C25D 17/00* (2006.01)

(21) International Application Number:
PCT/US2025/017300

(22) International Filing Date:
26 February 2025 (26.02.2025)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data:
63/558,416 27 February 2024 (27.02.2024) US

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(81) Designated States *(unless otherwise indicated, for every kind of national protection available)*: AE, AG, AL, AM, AO, AT, AU, AZ, BA, BB, BG, BH, BN, BR, BW, BY, BZ, CA, CH, CL, CN, CO, CR, CU, CV, CZ, DE, DJ, DK, DM, DO, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, GT, HN, HR, HU, ID, IL, IN, IQ, IR, IS, IT, JM, JO, JP, KE, KG, KH, KN, KP, KR, KW, KZ, LA, LC, LK, LR, LS, LU, LY, MA, MD, MG, MK, MN, MU, MW, MX, MY, MZ, NA, NG, NI, NO, NZ, OM, PA, PE, PG, PH, PL, PT, QA, RO, RS, RU, RW, SA, SC, SD, SE, SG, SK, SL, ST, SV, SY, TH, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UY, UZ, VC, VN, WS, ZA, ZM, ZW.

(84) Designated States *(unless otherwise indicated, for every kind of regional protection available)*: ARIPO (BW, CV, GH, GM, KE, LR, LS, MW, MZ, NA, RW, SC, SD, SL, ST, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, RU, TJ, TM), European (AL, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HR, HU, IE, IS, IT, LT, LU, LV, MC, ME, MK, MT, NL, NO, PL, PT, RO, RS, SE, SI, SK, SM, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, KM, ML, MR, NE, SN, TD, TG).

**Published:**
— *with international search report (Art. 21(3))*

WO 2025/184147 A1

(54) Title: INERT ANODE REACTION CHAMBER

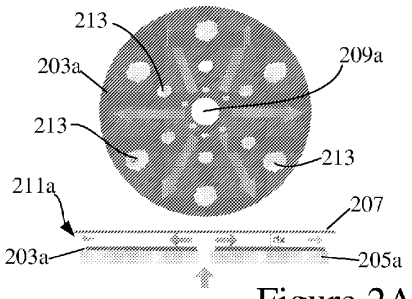


Figure 2A

(57) Abstract: An anode chamber for an electroplating apparatus includes an inert anode, an anode support in contact with the inert anode, an ionically conductive membrane separated from the inert anode by a gap in the anode chamber, a membrane clamp configured to hold the ionically conductive membrane, at least one inlet configured to flow anolyte into the gap at a first position, and at least one outlet configured to receive the anolyte flowing out of the gap at a second position.